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TECHNICAL REPORT



Environmental testing – Part 3-82: Supporting documentation and guidance – Confirmation of the performance of whisker test method

INTERNATIONAL ELECTROTECHNICAL COMMISSION

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The text of this Technical Report is based on the following documents:

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Full information on the voting for its approval can be found in the report on voting indicated in the above table.

The language used for the development of this Technical Report is English.

This document was drafted in accordance with ISO/IEC Directives, Part 2, and developed in accordance with ISO/IEC Directives, Part 1 and ISO/IEC Directives, IEC Supplement, available at www.iec.ch/members_experts/refdocs. The main document types developed by IEC are described in greater detail at www.iec.ch/publications.

A list of all parts in the IEC 60068 series, published under the general title *Environmental testing*, can be found on the IEC website.

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ENVIRONMENTAL TESTING -

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1 Scope

This part of IEC 60068, which is a Technical Report, provides technical background information on the whisker test methods from IEC 60068-2-82 and guidance on test selection.

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

IEC 60068-2-82:2019, Environmental testing – Part 2-82: Tests – Test XW1: Whisker test methods for components and parts used in electronic assemblies

IEC 61190-1-1, Attachment materials for electronic assembly – Part 1-1: Requirements for soldering fluxes for high-quality interconnections in electronics assembly

IEC 62483, Environmental acceptance requirements for tin whisker susceptibility of tin and tin alloy surface finishes on semiconductor devices

ISO 9454-2:2020, Soft soldering fluxes – Classification and requirements – Part 2: Performance requirements